

2.2 Test description and execution

 $(1 - \varepsilon)d$

unipg

COLLECTION OF SILICON DETECTORS MECHANICAL PROPERTIES FROM STATIC AND DYNAMIC CHARACTERIZATION TEST CAMPAIGNS

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DAMPE ladders adhesive arrangement

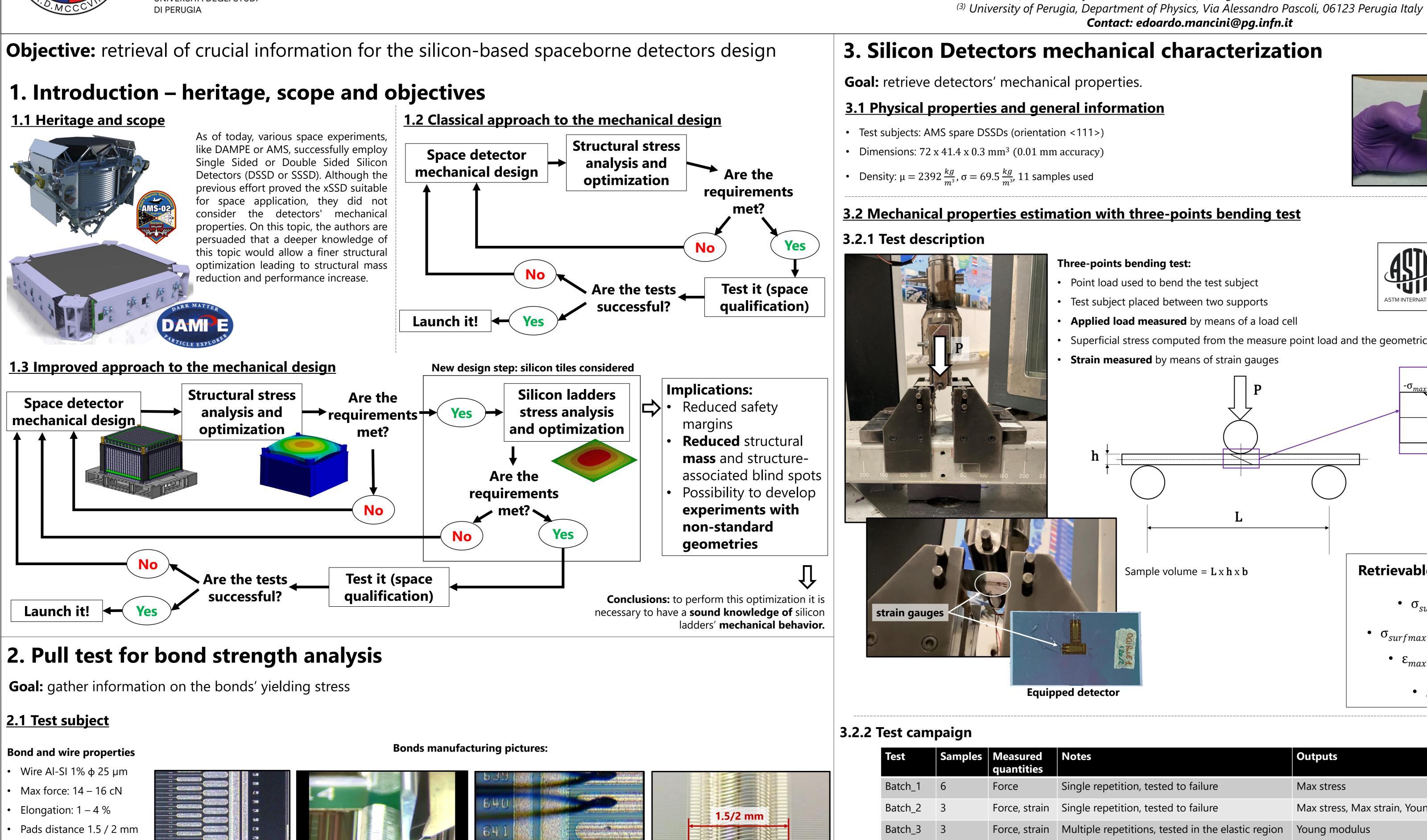
3 dB damping

in the frequency

estimation method,

electrically

conductive



Set-up:

 $\Rightarrow |_{d}$

750 µm

0 µm

1.5 mm

0.5

Test objective: verify the bonds' quality

Requirements: bond failure above

(good surface adhesion)

threshold, wire failure

3. Silicon Detectors mechanical characterization

- 3.1 Physical properties and general information
- 3.2 Mechanical properties estimation with three-points bending test



- **Applied load measured** by means of a load cell
- Superficial stress computed from the measure point load and the geometrical properties
- Strain measured by means of strain gauges



Sample volume = $\mathbf{L} \times \mathbf{h} \times \mathbf{b}$

Retrievable information: • $\sigma_{surf} = \frac{31L}{4hh^2}$

Performed in accordance will ASTM Standa

ASTM INTERNATIONAL D 7264 - 07

• $\varepsilon_{max} = \varepsilon_{@failure}$ • $E = \frac{\Delta \sigma}{\Delta}$

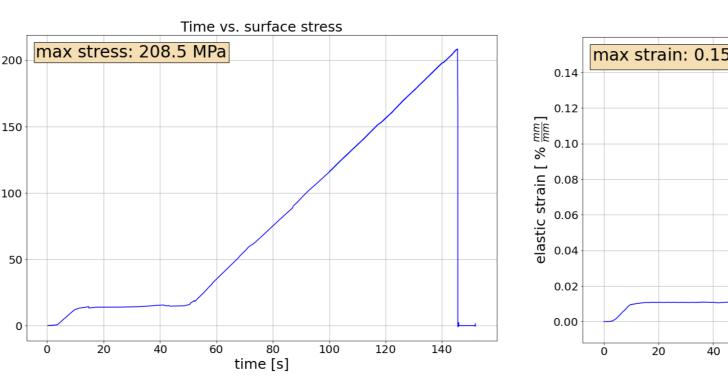
Test	Samples	Measured quantities	Notes	Outputs
Batch_1	6	Force	Single repetition, tested to failure	Max stress
Batch_2	3	Force, strain	Single repetition, tested to failure	Max stress, Max strain, Young modulus
Batch_3	3	Force, strain	Multiple repetitions, tested in the elastic region	Young modulus
Batch_4	2	Force, strain	Multiple repetitions, tested in the elastic region	Young modulus

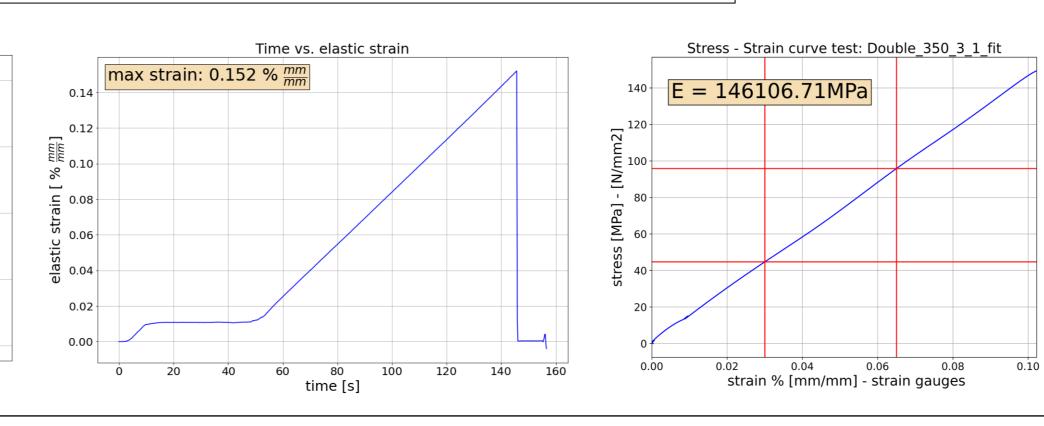
Results:

- Max stress: $\mu = 251.15$ MPa, $\sigma = 70.60$ MPa, 9 samples
- Max strain: $\mu = 0.1457\% \frac{m}{m}$, $\sigma = 0.0430\% \frac{m}{m}$, 3 samples
- Young modulus: $\mu = 142.19$ GPa, $\sigma = 10.19$ GPa, 5 samples 23 repetitions

Results: Pull force: $\mu = 12.471 \, \text{gf} *$, $\sigma = 1.7957 \text{ gf *}$ 515 samples

*gram-force





4. Adhesive damping estimation

Goal: estimate the effect of the adhesive on the detectors' dynamic response with a particular focus on damping.

Continous lines

4.1 Introduction

Space components are subjected to vibrations and shocks. The stresses coming from these dynamic loads are strongly dependent on the system damping.

At the same time, the damping depends on how the detector bonding materials. On this topic, a previous study demonstrated the critical role of

Two different types of glue are employed to form the bond between the detective tiles and the substrate (generally a PCB or Kapton foil): the first, structural, ensures the mechanical bond between substrate and polarization by electrically connecting it to the bias path on the substrate.

4.2 Structural glue

Shock test performed on DAMPE Quarte Plane The failed test on DAMPE mock-up shown the need for a less stiff and more elastic adhesive.

Epoxy glue, E ~ 1-2 GPa

 $\xi = 0.1085$

Silicon glue, E ~ 1-2 Mpa

Since then, silicon glue has been employed in the assembly of detectors due to its higher

compliance and energy-damping properties. With this solution, the system is less rigid, and the shock-associated high-frequency stresses

Case 1

Frequency [Hz]

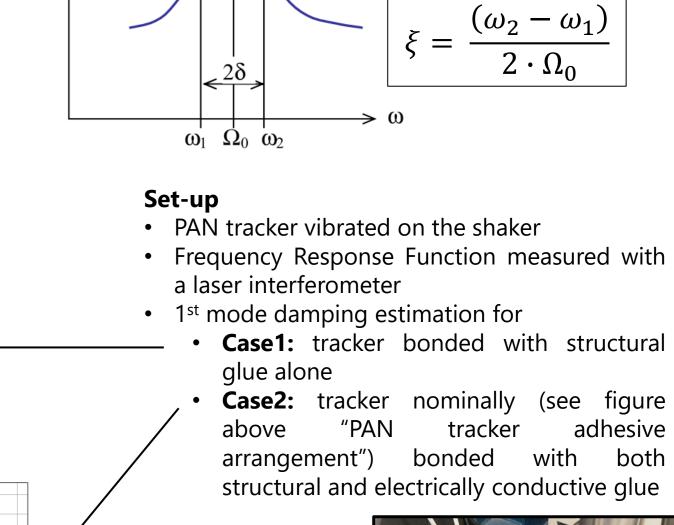
4.3 Conductive glue

Introduction Although remarkably beneficial, the glue substitution does not completely solve the problem. Indeed, the conductive glue is as well epoxy based. Hence, the need to study the effect of this

glue on the system dynamics. For this reason, the authors estimated the system damping for two different bonds.

Case 2

Frequency [Hz]

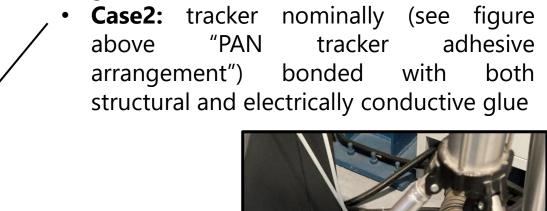


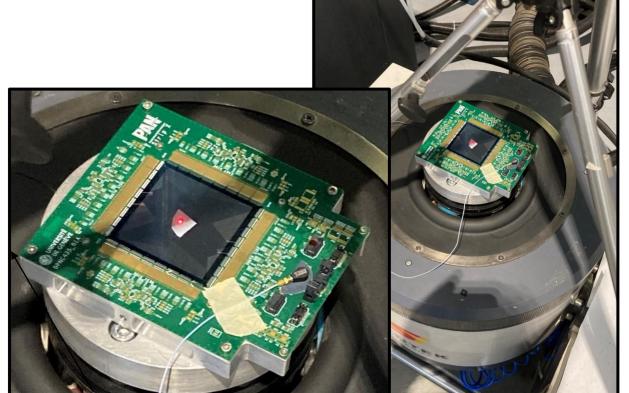
↑ 20·log |(H(ω))|

Continous

lines of

structural





Results:

 $\xi = 0.0425$

- Stresses on the detector, especially those shock-associated, can be reduced by employing silicon-based glues in place of epoxy-based ones.
- A over usage of electrically conductive glue is hazardous for the detectors since the former glue increases the detector-substate bonding stiffness and reduces the bond's energy dissipation capabilities.